

## EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	584	438/299.ccls.	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2006/07/20 17:49
L2	1358	438/301.ccls.	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2006/07/20 17:34
L3	1341	438/303.ccls.	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2006/07/20 17:50
L4	238	438/304.ccls.	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2006/07/20 17:35
L5	1770	438/655.ccls.	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2006/07/20 17:52
L6	673	438/682.ccls.	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2006/07/20 17:54

**EAST Search History**

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	0	method.clm. and (isolating adj element).clm. and (first adj insulating).clm. and width.clm. and (first adj2 semiconductor adj2 region).clm. and (second adj insulating).clm. and (remov\$ adj3 top).clm. and (ar adj2 sputter adj2 etching).clm. and (cobalt adj silicide).clm.	US-PGPUB	OR	ON	2006/07/20 18:00
L2	0	method.clm. and (isolating adj element).clm. and (first adj insulating).clm. and width.clm. and sidewalls.clm. and (source adj drain).clm. and depth.clm. and (remov? adj3 top).clm. and (ar adj2 sputter adj2 etching).clm. and (cobalt adj silicide).clm.	US-PGPUB	OR	ON	2006/07/20 18:01
L3	0	method.clm. and (isolating adj element).clm. and (gate adj insulating).clm. and width.clm. and sidewalls.clm. and (source adj drain).clm. and depth.clm. and (remov? adj3 top).clm. and (ar adj2 sputter adj2 etching).clm. and (cobalt adj silicide).clm.	US-PGPUB	OR	ON	2006/07/20 18:01